

Document downloaded from:

<http://hdl.handle.net/10251/82771>

This paper must be cited as:

Morro, JV.; Rodríguez Pérez, AM.; Belenguer Martínez, À.; Esteban González, H.; Boria Esbert, VE. (2016). Multilevel transition in empty substrate integrated waveguide. *Electronics Letters*. 52(18):1543-1544. doi:10.1049/el.2016.2558.



The final publication is available at

<http://dx.doi.org/10.1049/el.2016.2558>

Copyright Institution of Engineering and Technology (IET)

Additional Information

This paper is a postprint of a paper submitted to and accepted for publication in *Electronics Letters* and is subject to Institution of Engineering and Technology Copyright. The copy of record is available at the IET Digital Library.

Multilevel transition in empty substrate integrated waveguide

Jose V. Morro, Ana Rodríguez, Angel Belenguer, Héctor Esteban, and Vicente Boria

Empty Substrate Integrated Waveguide (ESIW) is an improvement of the well known Substrate Integrated Waveguide (SIW). While maintaining the low cost, easy manufacturing, small size, and integration with other circuits in the same substrate, ESIW decreases the related losses by removing the dielectric substrate, thus rendering it more interesting for practical applications. A wide band transition has been already developed to connect ESIW to microstrip lines. Filters, couplers and antennas have also been developed in ESIW. For multilevel configurations, where different ESIW devices are implemented in different stacked substrates, a transition is needed that connects ESIW lines in different substrate levels. In this work a low reflection wideband transition is presented for connecting two stacked ESIW lines.

Introduction: The Empty Substrate Integrated Waveguide (ESIW) [1] was the first waveguide integrated in a substrate that improved significantly the performance of the well known substrate integrated waveguides (SIW) by removing the dielectric, and thus decreasing the related insertion losses. There is a growing interest in ESIW, since other implementations have appeared recently (the hollow substrate integrated waveguide (HSIW) [2], the air filled substrate integrated waveguide [3], the dielectricless substrate integrated waveguide presented in [4], and the empty substrate integrated coaxial line (ESICL) [5]).

The ESIW has already been successfully tested with the design and manufacturing of coupled cavity filters with very high quality factors [1], a horn antenna [6], and a hybrid directional coupler [7]. In all these devices, a wideband transition has been used to connect the ESIW to accessing microstrip lines. However, for multilevel configurations, where different ESIW devices are implemented in different stacked substrates, a transition is needed that connects ESIW lines in different substrate levels.

In this work a wideband and low reflection transition that connects two stacked ESIW lines (placed in different layers) is presented.

Stacked ESIW: An ESIW line consists of an emptied and metallized substrate closed with a top and a bottom metallic layers that act as the top and bottom walls of the waveguide (see [1]). The transition between two stacked ESIW is composed of a top and a bottom cover of height h_{cov} , two emptied substrates (one for each ESIW) of height h , and a central layer with a coupling slot that couples both ESIW lines of height h_c , as shown in figure 1(f). It can be observed that the central layer (see figure 1(c) and figure 1(f)) has a coupling slot of width a and length l_c , where a is the width of the ESIW lines (see figures 1(a) and 1(d)). All the layers of the transition are of length l_x and width l_y . In order to improve the matching, the substrates of height h , where the ESIW lines of width a are mechanized, are lowered near the slot. They are lowered in height by $(v_c - h_c)/2$, a distance $l_s + l_c/2$ (see figures 1(f), 1(b) and 1(d)), so that the waves traveling through the first ESIW line find an stair-like path that leads to the other ESIW line when they reach the coupling slot (see figure 1(f)). When the geometrical dimensions are optimized, this stair-like path greatly minimizes the reflections and the return losses.

Figure 2 shows the 3D view of the transition modeled with the full wave simulator Computer Science Technology (CST), and the assembling of the five layers can be observed. Figure 2(a) shows the transition with only the bottom cover and the bottom ESIW line. The transition from ESIW to microstrip at the end of the ESIW line can be observed [1]. It can also be observed how the ESIW line ends in a short circuit, but the height of this short circuit is lowered at the beginning (a distance $l_s + l_c/2$ as shown in figure 1(d)), in order to improve the matching. Figure 2(b) shows the transition when the central layer is stacked. The coupling slot of dimensions $a \times l_c$ can be observed. The mechanization with a drill machine produces rounded corners. The radius of these rounded corners (0.5 mm) is the radius of the drill used for mechanizing. Figure 2(c) shows the transition when the top ESIW line has been added. In this top view can not be observed, but this layer has also been lowered in the bottom view (as shown in figure 1(b)). Finally, figure 2(d) shows the whole transition when the top cover has also been assembled.

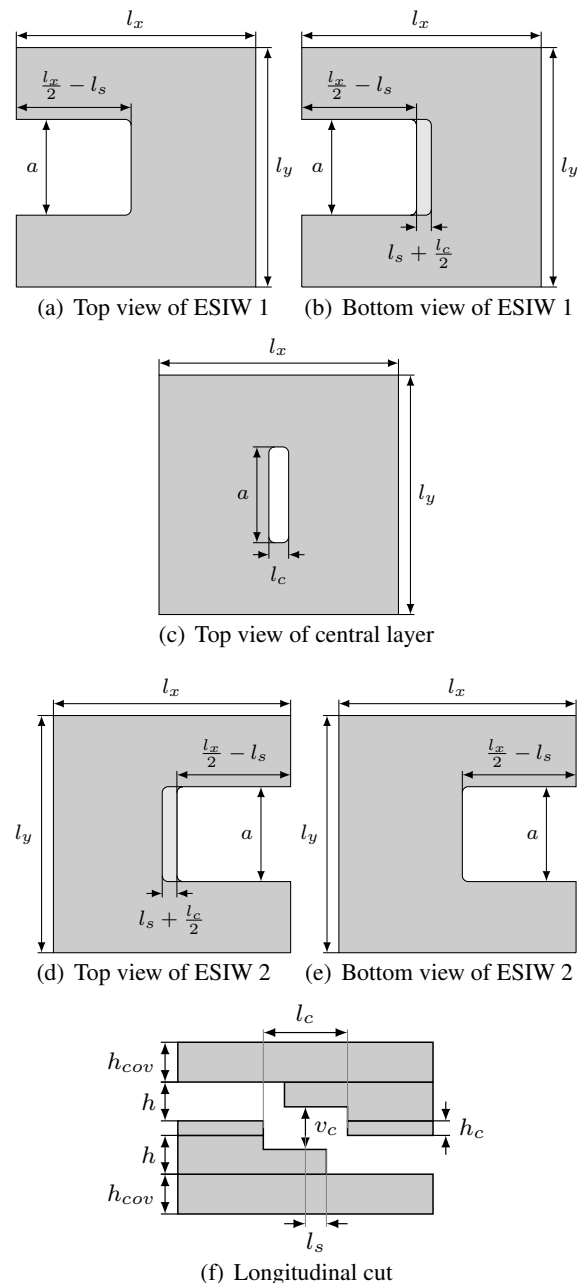


Fig. 1 Layout of the different layers of the multilevel transition. Light gray represents the copper metallization on both layers; black represents the metallization of the lateral walls; and white is air.

Design: A transition has been designed for an ESIW line of the same width as the WR-62 ($a = 15,799$ mm). The design goal is to minimize the return loss in all the usable frequency band of the WR-62 (from 12 to 18 GHz). Rogers 4003C substrates of $\epsilon_r = 3,55$ have been used for the two ESIW layers and also for the central layer. The substrate height for the ESIW layers is 1,524 mm, and 0,508 mm for the central layer. FR4 substrates of height 1,5 mm have been used for the top and bottom covers. All the substrates come with a copper foil of $35 \mu\text{m}$ of thickness, but after being drilled an additional layer of $25 \mu\text{m}$ of electrodeposited copper is added. Consequently, the heights of all the layers are $h = 1,524 + 2 \cdot 0,035 + 2 \cdot 0,025 = 1,644$ mm, $h_c = 0,508 + 2 \cdot 0,035 + 2 \cdot 0,025 = 0,628$ mm, and $h_{cov} = 1,5 + 2 \cdot 0,035 + 2 \cdot 0,025 = 1,62$ mm, as shown in table 1. In this table the chosen values for the width and length of all the layers (l_x and l_y) is also shown. The rest of the parameters of table 1 (l_c , l_s and v_c) are the design parameters. Using the CST simulator, these parameters have been optimized with the goal of minimizing the return losses in all the usable frequency band. The resulting optimized values are the ones presented in table 1.

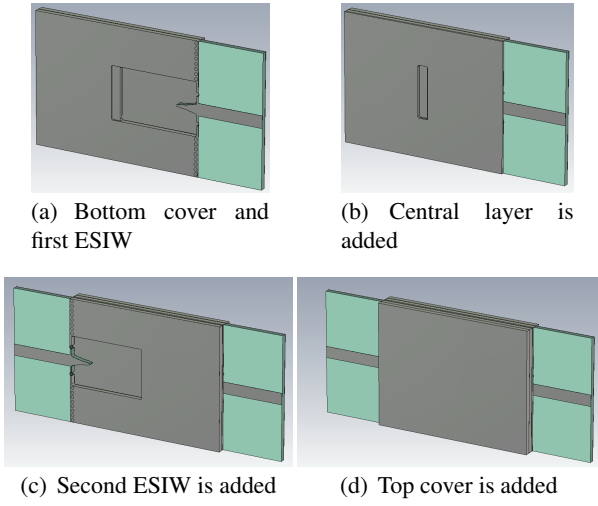


Fig. 2 Schematic 3D views of the stacked ESIW transition, with the assembling procedure of the 5 layers. (a) Bottom cover and first ESIW line. (b) Central layer is added. (c) Second ESIW is added. (d) Top cover is added and the assembling is completed

Results: Figure 3 shows the manufactured prototype before assembling. The five layers can be observed. All the layers have been drilled with holes for alignment screws. Tin soldering paste is placed between adjacent layers and then it is dried in a reflow oven. Once the soldering paste is dried, the alignment screws are removed.

Once assembled, the manufactured prototype of figure 3 has been measured with a network analyzer. Measurements and simulated results are compared in figure 4. There is a good agreement between simulation and measurements. Measured return losses are above 18 dB in all the usable frequency band. Insertion losses are below 1 dB.

l_x	l_y	a	l_c	l_s
40	39.05	15.7988	3.3237	0.8209
v_c	h	h_{cov}	h_c	
1.6735	1.644	1.62	0.628	

Table 1: Dimensions of the multilevel transition (all dimensions in mm)

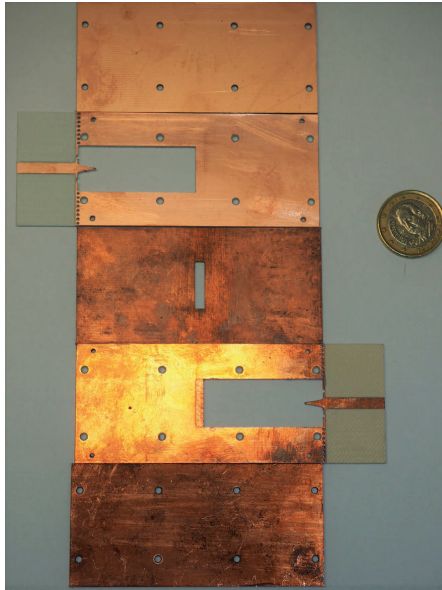


Fig. 3. Vertically stacked ESIW before assembling.

Conclusion: A novel transition for multilevel ESIW configurations has been presented. The transition is simple to manufacture and design. A prototype has been manufactured for an ESIW of the same width as the

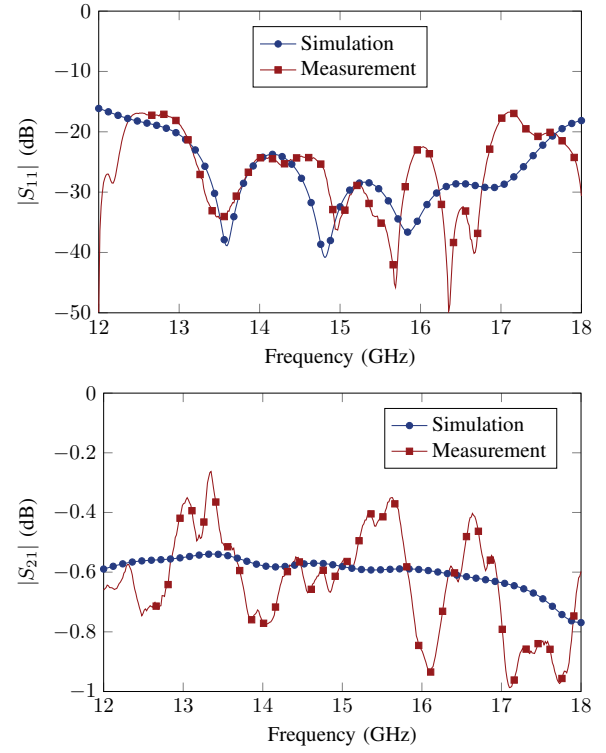


Fig. 4 Comparison between simulation and measurements for the manufactured stacked ESIW transition

WR-62. Measured return losses are above 18 dB and insertion loss below 1 dB in all the usable frequency band of the ESIW.

Acknowledgment: This work was supported by the Ministerio de Economía y Competitividad, Spanish Government, under Research Projects TEC2013-47037-C05-3-R and TEC2013-47037-C05-1-R.

J. V. Morro, A. Rodríguez, H. Esteban, and V. E. Boria (*Universitat Politècnica de València, Spain*)

A. Belenguier (*Universidad de Castilla-La Mancha, Spain*)

E-mail: hesteban@dcom.upv.es

References

- 1 A. Belenguier, H. Esteban, and V. Boria, "Novel empty substrate integrated waveguide for high-performance microwave integrated circuits," *Microwave Theory and Techniques, IEEE Transactions on*, vol. 62, no. 4, pp. 832–839, April 2014.
- 2 L. Jin, R. Lee, and I. Robertson, "Analysis and design of a novel low-loss hollow substrate integrated waveguide," *Microwave Theory and Techniques, IEEE Transactions on*, vol. 62, no. 8, pp. 1616–1624, Aug 2014.
- 3 F. Parment, A. Ghiotto, T.-P. Vuong, J.-M. Duchamp, and K. Wu, "Air-filled substrate integrated waveguide for low-loss and high power-handling millimeter-wave substrate integrated circuits," *Microwave Theory and Techniques, IEEE Transactions on*, vol. 63, no. 4, pp. 1228–1238, April 2015.
- 4 F. Bigelli, D. Mencarelli, M. Farina, G. Venanzoni, P. Scalmati, C. Renghini, and A. Morini, "Design and fabrication of a dielectricless substrate-integrated waveguide," *Components, Packaging and Manufacturing Technology, IEEE Transactions on*, vol. 6, no. 2, pp. 256–261, Feb 2016.
- 5 A. Belenguier, A. Borja, H. Esteban, and V. Boria, "High-performance coplanar waveguide to empty substrate integrated coaxial line transition," *Microwave Theory and Techniques, IEEE Transactions on*, vol. 63, no. 12, pp. 4027–4034, Dec 2015.
- 6 J. Mateo, A. Torres, A. Belenguier, and A. Borja, "Highly efficient and well-matched empty substrate integrated waveguide H-plane horn antenna," *Antennas and Wireless Propagation Letters, IEEE*, vol. PP, no. 99, pp. 1–1, 2016.
- 7 M. Fernandez, J. Ballesteros, and A. Belenguier, "Design of a hybrid directional coupler in empty substrate integrated waveguide (ESIW)," *Microwave and Wireless Components Letters, IEEE*, vol. 25, no. 12, pp. 796–798, Dec 2015.